IN THE SPECIFICATION

Page 87, amend the paragraph beginning at line 9 as follows:

Getter region 112 lies over a support region consisting primarily of base focusing structure 108. In the electron-emitting light-emitting device of Figs. 19 and 20, the support region also includes focus coating 110 on which region 112 directly lies. Region 112 is normally situated on at least part of the top surface of electron-focusing system 108/110 and extends at least partway down the sidewalls of system 108/110 into focus openings 118. Figs. 19 and 20 depict an exemplary case in which region 112 is situated on largely the entire top surface of coating 110 and extends down the vertical portions of coating 110 but does not extend significantly beyond coating 110. Region 112 normally has a thickness of 0.1 - 10 μ m, typically 2 μ m.